

	Hits	Search Text	DBs
22	23	((under or bottom or conductive or metal\$4 or dielectric) near14 (deposit\$4 or form\$3 or layer or film or coat\$3)) and ((photoresist or resist or photo\$4cur\$4 or photo\$3imageable) same (novolac or epoxy or resin\$3 or \$5hydroxystyrene) same (photoactive or PAC or non\$6chemical\$5active or non\$6chemical\$8amplif\$8) same (expos\$4 or illuminat\$4 or irradiat\$4) same pattern\$4) and develop\$4 and ((solubilization or \$3solubilizing or soluble or solubility or insoluble) same (prevent\$4 or caus\$4 or inhibit\$4)) and \$6hydroxystyrene	US - PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB
23	5	(non\$5chemical\$5 near9 (amplification or amplify or amplified)) and (chemical\$4 near12 (amplification or amplify or amplified)) and (resist or photoresist or photosensitive) and resin\$4 and photo\$4active and develop\$4 and ((solubilization or \$3solubilizing or soluble or solubility or insoluble) same (prevent\$4 or caus\$4 or inhibit\$4)) and polyhydroxystyrene	US - PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB

	Hits	Search Text	DBs
24	6	(non\$2chemical\$5 near9 (amplification or amplify or amplified)) and (chemical\$4 near12 (amplification or amplify or amplified)) and (resist or photoresist or photosensitive) and photo\$3active and develop\$4 and (solubilization or \$3solubilizing or soluble or solubility or insoluble) and polyhydroxystyrene	US - PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB
25	5	(non\$2chemical\$5 near9 (amplification or amplify or amplified)) and (chemical\$4 near12 (amplification or amplify or amplified)) and (resist or photoresist or photosensitive) and photo\$3active and develop\$4 and poly\$4hydroxystyrene	US - PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB
26	6	(non\$2chemical\$5 near9 (amplification or amplify or amplified)) and (chemical\$4 near12 (amplification or amplify or amplified)) and (resist or photoresist or photosensitive) and resin\$4 and photo\$2active and develop\$4 and ((solubilization or \$3solubilizing or soluble or solubility or insoluble) same (prevent\$4 or caus\$4 or inhibit\$4))	US - PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB

	Hits	Search Text	DBs
27	10	(non\$5chemical\$5 near9 (amplification or amplify or amplified)) and (chemical\$4 near12 (amplification or amplify or amplified)) and (resist or photoresist or photosensitive) and resin\$4 and photo\$4active and develop\$4 and ((solubilization or \$3solubilizing or soluble or solubility or insoluble) same (prevent\$4 or caus\$4 or inhibit\$4))	US-PPGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB
28	6	(("6444408") or ("6340734") or ("6087064") or ("5385804") or ("5338818") or ("5985524")).PN.	US-PPGPUB; USPAT
29	15	((non\$3chemical\$5 near9 (amplification or amplify or amplified)) same (chemical\$4 near12 (amplification or amplify or amplified))) and (resist or photoresist or photosensitive) and resin\$4 and photo\$4active and develop\$4	US-PPGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB
30	1	((non\$3chemical\$5 near9 (amplification or amplify or amplified)) same (chemical\$4 near12 (amplification or amplify or amplified))) and (photoactive near26 phenyl)	US-PPGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB
31	1	((non\$3chemical\$5 near9 (amplification or amplify or amplified)) same (chemical\$4 near12 (amplification or amplify or amplified))) and (photoactive same phenyl)	US-PPGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB

	Hits	Search Text	DBs
32	66	((non\$3chemical\$5 near9 (amplification or amplify or amplified)) same (chemical\$4 near12 (amplification or amplify or amplified)) same (modif\$6 or replac\$4 or displac\$4 or chang\$4 or using or use))	US - PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB
33	60	S36 NOT S33	US - PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB